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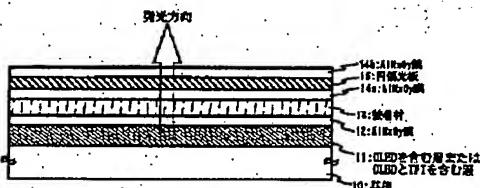
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(54) LIGHT EMITTING EQUIPMENT AND ELECTRONIC DEVICE, AND ORGANIC POLARIZING FILM

(57) Abstract:

PROBLEM TO BE SOLVED: To provide light emitting equipment, which can suppress degradation by diffusion of impurities, such as moisture, oxygen, alkaline metals, and alkaline-earth metals, and specifically to provide flexible light emitting equipment which has OLED formed on a plastic substrate.

SOLUTION: The barrier films 14a and 14b, which consist of a layer shown by AlN_xO_y , a layer shown by AlX_3N_y , or a layer shown by Al_2O_3 , which prevent oxygen and moisture entering into the organic light emitting layer of OLED, and are possible to prevent impurities such as alkaline metals, alkaline-earth metals, and the like entering into an active layer of TFT, are provided with a single layer or two or more layers on a circular polarizing plate 15, in the light emitting equipment using the substrate 10.



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